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| APPLICATION NO. | FILING DATE | FIRST NAMED INVENTOR | ATTORNEY DOCKET NO. | CONFIRMATION NO. | |
|--------------------|----------------------------------|----------------------|---------------------|------------------|--|
| 10/566,170 | 01/27/2006 | Yoshinobu Sekiguchi | 00862.109138. | 2513 | |
| | 7590 04/10/200 CELLA HARPER & | EXAMINER | | | |
| 30 ROCKEFEL | | LEE, CALVIN | | | |
| NEW YORK, NY 10112 | | | ART UNIT | PAPER NUMBER | |
| | | | 2892 | | |
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| | | | MAIL DATE | DELIVERY MODE | |
| | | | 04/10/2008 | PAPER | |

Please find below and/or attached an Office communication concerning this application or proceeding.

The time period for reply, if any, is set in the attached communication.

| Supplementary | |
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| Notice of Allowability | / |

| Application No. | Applicant(s) | |
|-----------------|------------------|--|
| 10/566,170 | SEKIGUCHI et al. | |
| Examiner | Art Unit | |
| Calvin Lee | 2892 | |

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|---|--|---|---------------------------|
| | Calvin Lee | 2892 | |
| The MAILING DATE of this communication appearance All claims being allowable, PROSECUTION ON THE MERITS IS herewith (or previously mailed), a Notice of Allowance (PTOL-85) NOTICE OF ALLOWABILITY IS NOT A GRANT OF PATENT R of the Office or upon petition by the applicant. See 37 CFR 1.313 | (OR REMAINS) CLOSED in this app or other appropriate communication IGHTS. This application is subject to | olication. If not include will be mailed in due | ed course. THIS |
| 1. X This communication is responsive to <u>Telephone Interview</u> | dated April 3, 2008. | | |
| 2. ⊠ The allowed claim(s) is/are <u>17-31</u> . | | | |
| 3. Acknowledgment is made of a claim for foreign priority ur a) All b) Some* c) None of the: 1. Certified copies of the priority documents have 2. Certified copies of the priority documents have | e been received. | | |
| 3. ☐ Copies of the certified copies of the priority do | | | tion from the |
| International Bureau (PCT Rule 17.2(a)). | | | |
| * Certified copies not received: | | | |
| Applicant has THREE MONTHS FROM THE "MAILING DATE" noted below. Failure to timely comply will result in ABANDONN THIS THREE-MONTH PERIOD IS NOT EXTENDABLE. | | complying with the red | quirements |
| 4. A SUBSTITUTE OATH OR DECLARATION must be subm INFORMAL PATENT APPLICATION (PTO-152) which give | | | OTICE OF |
| 5. CORRECTED DRAWINGS (as "replacement sheets") mus | st be submitted. | | |
| (a) ☐ including changes required by the Notice of Draftspers | | 948) attached | |
| 1) hereto or 2) to Paper No./Mail Date | • | | |
| (b) ☐ including changes required by the attached Examiner's Paper No./Mail Date | s Amendment / Comment or in the C | office action of | |
| Identifying indicia such as the application number (see 37 CFR 1 each sheet. Replacement sheet(s) should be labeled as such in t | | | back) of |
| DEPOSIT OF and/or INFORMATION about the depo attached Examiner's comment regarding REQUIREMENT | | | Note the |
| | | | |
| Attachment(s) | _ | | |
| 1. Notice of References Cited (PTO-892) | 5. Notice of Informal P | | |
| 2. Notice of Draftperson's Patent Drawing Review (PTO-948) | 6. ☐ Interview Summary Paper No./Mail Dat | (PTO-413), e . | |
| 3. Information Disclosure Statements (PTO/SB/08), | 7. 🛛 Examiner's Amendn | | |
| Paper No./Mail Date 4. | 8. Examiner's Stateme | nt of Reasons for Allo | wance |
| - | 9. | | |
| | /Calvin Lee/ | | |
| | Primary Examiner Art Unit: 2892 | | |

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Docket: 00862.109138 SEKIGUCHI et al.

OFFICE ACTION

(Supplementary)

Examiner's Amendment

1. An examiner's amendment to the record appears below. Should the changes and/or additions be unacceptable to applicant, an amendment may be filed as provided by 37 CFR 1.312. IN THE SPECIFICATION: First page, after the title, inserted:

-- This application is a 371 of PCT/JP05/11388, filed on June 15, 2005, and titled "Semiconductor Film Manufacturing Method and Substrate Manufacturing Method," which claims priority under 35 U.S.C. § 119 to Japanese Application No. 2004-185237, filed on June 23, 2004, the entire contents of which are hereby incorporated by reference.--

Allowable Subject Matter

- 2. Claims 17-31 are allowed. Following is the Examiner's statement reason for allowance:
- None of the cited arts teaches or suggests "hetero-epitaxially growing a separation layer on a separation assisting layer," "forming a semiconductor film on the separation layer," and "bonding a seed substrate with the separation layer and the semiconductor film to a handle substrate while setting the separation layer inside," as set for with the rest process steps of forming a semiconductor film separated from a seed substrate.
- 3. Any comments considered necessary by applicant must be submitted no later than the payment of the issue fee and, to avoid delays, should preferably accompany the issue fee. Such submissions should be clearly labeled "Comments on Statement of Reasons for Allowance."

Contact Information

4. Any inquiry concerning this communication from the Examiner should be directed to Calvin Lee at (571) 272-1896 on Mondays thru Thursdays 6:30-4:30 (EST). If attempts to reach the examiner by telephone are unsuccessful, Art Unit 2892's Supervisory Patent Examiner Thao X. Le can be reached at (571) 272-1708. The central fax number for the organization is (571) 273-8300.

Information regarding the status of an application may be obtained from the Patent Application Information Retrieval (PAIR) system at http://pair-direct.uspto.gov Should you have questions on access to the PAIR system, contact the Electronic Business Center at (866) 217-9197.

Dated: April 4th, 2008 /Calvin Lee/